

## ABSTRACT

A plasma-resistant member used in a reaction chamber of a plasma treating apparatus is formed of a dense alumina sintered product having an average grain size of 18 - 45  $\mu\text{m}$ , a surface roughness Ra of 0.8 - 3.0  $\mu\text{m}$  and a bulk density of 3.90  $\text{g}/\text{cm}^3$  or over.

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